

ABSTRACT

**PROCESS FOR MANUFACTURING A STRUCTURE COMPRISING AT LEAST TWO
TILES ON A SUBSTRATE**

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The invention relates to a process for manufacturing a structure comprising at least two tiles on a substrate, comprising:

- 10 - placing, on a support substrate (1, 3, S), at least two tiles ((P1, P2), (P'1, P'2)), said tiles being arranged on said support substrate (1, 3, S) in an incorrect distribution and/or geometry compared with a target distribution and/or geometry;
- forming a mask comprising a protective film (M1, M2) partially covering said tiles ((P1, P2), (P'1, P'2)) in a pattern defining the target distribution and/or geometry and at least one opening extending around the protective film (M1, M2);
- 15 - etching at least one tile ((P1, P2), (P'1, P'2)) through the opening in the mask so as to correct the arrangement of the tiles according to the target distribution and/or geometry.

Figure 6